



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/920,978
 Filing Date August 1, 2001
 Inventor Shane J. Trapp
 Assignee Micron Technology, Inc.
 Group Art Unit 2813
 Examiner David S. Blum
 Attorney's Docket No. MI22-1674
 Title: Method of Forming Integrated Circuitry and Method of Forming Shallow
 Trench Isolation in a Semiconductor Substrate

RESPONSE TO JANUARY 13, 2003 FINAL OFFICE ACTION
PRELIMINARY AMENDMENT TO ACCOMPANY RCE FILING

To: Box RCE
 Assistant Commissioner for Patents
 Washington, D.C. 20231

VIA EXPRESS MAIL

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Responsive to the Final Office Action dated January 13, 2003, Applicant
 amends and remarks as follows:

AMENDMENTS